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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/519,333 06/23/2005		Fredrik Nikolajeff	514862001700	9310	
20872 759	90 03/23/2006		EXAMINER		
MORRISON & FOERSTER LLP			RAHLL, JERRY T		
425 MARKET STREET SAN FRANCISCO, CA 94105-2482			ART UNIT	PAPER NUMBER	
om man con	,00, 011 71105 2102		2874		
			DATE MAILED: 03/23/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

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			Applicatio	n No.	Applicant(s)			
Office Action Summary		10/519,33	3	NIKOLAJEFF ET AL.				
		Examiner		Art Unit				
		Jerry T. Ra		2874				
The MAI Period for Reply	LING DATE of this commun	ication app	ears on the	cover sheet with the c	orrespondence ad	dress		
WHICHEVER IS - Extensions of time if after SIX (6) MONT - If NO period for rep - Failure to reply with Any reply received	O STATUTORY PERIOD F S LONGER, FROM THE M may be available under the provisions HS from the mailing date of this comm ly is specified above, the maximum sta in the set or extended period for reply by the Office later than three months a adjustment. See 37 CFR 1.704(b).	IAILING DA of 37 CFR 1.13 nunication. atutory period w will, by statute,	ATE OF THI 66(a). In no ever rill apply and will cause the appli	S COMMUNICATION nt, however, may a reply be time expire SIX (6) MONTHS from the cation to become ABANDONEI	l. ely filed the mailing date of this co D (35 U.S.C. § 133).			
Status								
1)☐ Responsi	ve to communication(s) file	ed on	_					
·	Responsive to communication(s) filed on This action is FINAL. 2b) This action is non-final.							
· 	3) Since this application is in condition for allowance except for formal matters, prosecution as to the me							
	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
	·		,	, ,,	•			
Disposition of Clai	ims							
4)⊠ Claim(s) <u>1</u>	Claim(s) <u>1-11</u> is/are pending in the application.							
4a) Of the	4a) Of the above claim(s) is/are withdrawn from consideration.							
5)⊠ Claim(s) <u>(</u>	☑ Claim(s) <u>6-11</u> is/are allowed.							
6)⊠ Claim(s) <u>1</u>	1-3, 5 is/are rejected.							
7)⊠ Claim(s) <u>4</u>	Claim(s) 4 is/are objected to.							
8) Claim(s) _	8) Claim(s) are subject to restriction and/or election requirement.							
Application Papers	· S							
9) The specif	ication is objected to by the	e Examiner						
				cepted or b) objecte	ed to by the Exam	iner		
10)⊠ The drawing(s) filed on <u>22 December 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).								
	ent drawing sheet(s) including		_	-	• •	R 1 121(d)		
	or declaration is objected to							
		, a.o _,			, 1011011 01 1011111 1	0 102.		
Priority under 35 L								
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
	rson's Patent Drawing Review (P sure Statement(s) (PTO-1449 or			4) Interview Summary (Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te)-152)		

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DETAILED ACTION

Information Disclosure Statement

1. The information disclosure statement (IDS) submitted on April 22, 2005 is in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure statement is being considered by the examiner.

Drawings

2. The drawings submitted have been reviewed and determined to facilitate understanding of the invention. The drawings are accepted as submitted.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 1-3 and 5 are rejected under 35 U.S.C. 102(b) as being anticipated by US Patent No 3,873,188 to Baeker.
- 5. Regarding claims 1-5, applicant is claiming the product including the process of origination of each of the mating alignment structures from the same microstructural element, and therefor are of "product-by-process" nature. The courts have been holding for quite some time that: the determination of the patentability of product-by-process claim is based on the product itself rather than on the process by which the product is made. In re Thrope, 777 F. 2d 695, 227 USPQ 964 (Fed. Cir. 1985); and patentability of claim to a product does not rest merely on a difference in the method by which that product is made. Rather, it is the product itself which must be new and unobvious.

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Applicant has chosen to claim the invention in the product form. Thus a prior art product which possesses the claimed product characteristics can anticipate or render obvious the claim subject matter regardless of the manner in which it is fabricated. A rejection based on 35 U.S.C. section 102 or alternatively on 35 U.S.C. section 103 of the status is eminently fair and acceptable. In re Brown and Saffer, 173 USPQ 685 and 688; In re Pilkington, 162 USPQ 147. As such no weight is given to the process steps recited in claims 1-5.

- 6. Regarding Claim 1, Baeker describes a multilayer device comprising first and second layers aligned by mating alignment structures, where the first layer (6) is a positive replication of a microstructural master (see Figures 3 and 4) and the second layer (7) is a negative replication of the same master.
- 7. Regarding Claim 2, Backer describes the replication including microstructural elements (8) other than alignment structures.
- 8. Regarding Claim 3, Backer describes the master having a deep microscale structure (12) and a shallow surface relief (8) aligned to each other by the mating alignment structures (12,13).
- 9. Regarding Claim 5, Backer describes the shallow surface relief as a diffractive structure.

Allowable Subject Matter

- 10. Claims 6-11 are allowed.
- 11. Claim 4 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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12. Claim 4 describes the deep microscale structure as a fiber aligning groove.

13. Claims 6-11 describe production of two copies of the master, where the first copy has the same polarity as the master and the second copy has the opposite polarity.

14. This is subject matter not described or reasonably suggested, in conjunction with the further limitations of the present claims, by the prior art of record.

Conclusion

15. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. US Patent No. 6,160,936 to You et al. describes a multilayer microstructural device with mating alignment structures.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jerry T. Rahll whose telephone number is (571) 272-2356. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Rodney Bovernick can be reached on (571) 272-2344. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business

Center (EBC) at 866-217-9197 (toll-free).

Jerry T Rahll

Michelle Connelly Cushwa
PRIMARY EXAMINER

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